DLA Land and Maritime - VQ Supplemental Information Sheet for Electronic QML-31032

Specification Details: Date: 3/17/2016

Specification: MIL-PRF-31032

Title: Printed Circuit Board/Printed Wiring Board

Federal Supply Class (FSC): 5998

Conventional: No

Specification contains quality assurance program: Yes MIL-STD-790 Established Reliability & High Reliability: No MIL-STD-690 Failure Rate Sampling Plans & Procedures: No

Weibull Graded: Yes

Specification contains space level reliability requirements: No

Specification allows test optimization: Yes

Contact Information:

Office of Primary Involvement: Electronic Devices Branch, DLA Land and Maritime - VQE

Primary Qualifying Activity Contact: 614-692-0627, e-mail: vqe.ls@dla.mil

Notes:

If a manufacturer desires to have test data considered for qualification, it must be certified and meet all qualification test requirements of MIL-PRF-31032 and the applicable associated specification.

The listing of printed board manufacturing lines in the QML applies only to printed boards produced in the plant(s) specified herein. Therefore, only those printed boards that have been manufactured and tested on the certified/qualified lines listed herein can be supplied as QML printed boards.

The DLA Land and Maritime - VQE contacts for QML companies can be located in the file "31032 main points-of-contact" at website: http://www.dscc.dla.mil/offices/sourcing and qualification/offices.asp?section=VQE

QML is a definition of a manufacturer's verified capabilities. Manufacturers may use the add-on qualification process to qualify capabilities that are not currently listed on the QML. The user is encouraged to contact the manufacturer or Qualifying Activity to make arrangements for QML availability.

The following abbreviations are used in this listing:

Ag: Silver Au: Gold

CAGE: Commercial and Government Entity (Code)

Cu: Copper

ENIG: Electroless Nickel Immersion Gold

HASL: Hot Air Solder Level ImmAg: Immersion Silver

IR: Infrared

LPI: Liquid Photoimageable MIX: Mix of SMT and THM

Ni: Nickel

OSP: Organic Surface Protection

Pb: Lead Pd: Palladium

PTH: Plated Thru Hole

SMOBC: Solder Mask Over Bare Copper

SMT: Surface-Mount Technology

Sn: Tin

THM: Through-Hole Mounting

MANUFACTURER INFORMATION:

AC Universal Circuits LLC

8860 Zachary Lane North, Maple Grove, MN, 55369-4524

LUS

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 45032

Phone: 763-315-1709 Fax: 763-425-0999

EMail: MG_Quality@4pcb.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-10-019530, VQE-10-020323, VQE-12-024534 Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .125"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.88:1 Through-Hole
Min. Conductor Width/Space: .0032"/.0032"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Carbon-based

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-10-019530, VQE-10-020323, VQE-12-024534

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .18"

Min. Hole Size: .021" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.57:1 Through-Hole Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Carbon-based

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

Additional Fab Capabilities: Blind Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-11-021326, VQE-12-024534

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 8
Max. Board Thickness: .062"

Min. Hole Size: .0138" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 4.5:1 Through-Hole
Min. Conductor Width/Space: .007"/.006"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Carbon-based

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

Additional Fab Capabilities: Foil Lamination

MANUFACTURER INFORMATION: PLANT LOCATION: Same Address as Manufacturer

Accurate Circuit Engineering

3019 S. Kilson Drive, Santa Ana, CA, 92707 US

CAGE Code: 0MNN9

Phone: 714-546-2162 714-433-7418 Fax:

EMail: quality@ace-pcb.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-06-012150, VQE-07-012577, VQE-09-018384, VQE-10-020411, VQE-11-022279, VQE-13-026528, VQE-13-026662

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 20" x 26" Max. Number of Layers: 24 Max. Board Thickness: .22"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

PLANT LOCATION: MANUFACTURER INFORMATION: CAGE Code: 6RJS1 Same Address as Manufacturer **Advanced Circuits - Tempe Division**

229 S. Clark Drive, Tempe, AZ, 85281-3073 US

Phone: 480-966-5894 Fax: 480-966-5896

EMail: tempesales@4pcb.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-024291, VQE-12-024631, VQE-12-025042, VQE-13-025402, VQE-13-025881

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 24 Max. Board Thickness: .125"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: .8:1 Microvia, 12.5:1 Through-Hole Min. Conductor Width/Space: .004"/.0033"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate, Periodic Reverse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-024291, VQE-12-024631, VQE-12-025042, VQE-13-025402, VQE-13-025881, VQE-15-029681

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 24 Max. Board Thickness: .125"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1.1:1 Microvia, 12.5:1 Through-Hole Min. Conductor Width/Space: .004"/.0033"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate, Periodic Reverse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION:

Airborn Flexible Circuits. Inc.

11 Dohme Avenue, Toronto, M4B 1Y7, Ontario Canada

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 38661

Phone: 416-285-3825 Fax: 416-752-6719

EMail: pialisp@airbornflex.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4 Qualification Letters: VQE-04-005354, VQE-08-015729

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 12" x 18" Max. Number of Layers: 7

Max. Board Thickness: "Not Specified Aspect Ratio: 3:1 Through-Hole Min. Conductor Width/Space: .007"/.007"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Direct Metalization

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: HASL

Additional Fab Capabilities: Copper Core, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4
Qualification Letters: VQE-04-005354, VQE-08-015729

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 12" x 18"

Max. Number of Layers: 12

Max. Board Thickness: .094"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 12:1 Through-Hole Min. Conductor Width/Space: .006"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Direct Metalization

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: HASL

Additional Fab Capabilities: Copper Core, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: Same Address as Manufacturer

American Standard Circuits

475 Industrial Drive, West Chicago, IL, 60185 US

CAGE Code: 4AA34

Phone: 603-639-5444 Fax: 603-293-1240 EMail: sales@asc-i.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-08-015934, VQE-11-021830, VQE-11-023138, VQE-13-025323, VQE-13-025791, VQE-13-025834

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 14

Max. Board Thickness: .09" (for /1, Type 3 - Multilayer), .125" (for /2, Type /2 - Double-sided only)

Min. Hole Size: .009" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg Additional Fab Capabilities: Blind Vias, Foil Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-11-022358, VQE-11-023138

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 10 Max. Board Thickness: .125"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-16-029852

Composition: M - Mixed based material printed boards, S - Homogenous thermosetting base material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 18" x 24" Max. Number of Layers: 10 Max. Board Thickness: .095"

Min. Hole Size: .017" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6:1 Through-Hole

Min. Conductor Width/Space: .004"/.004" Hole Preparation: Permanganate Desmear Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg

MANUFACTURER INFORMATION: PLANT LOCATION:

Amphenol Printed Circuits

91 Northeastern Boulevard, Nashua, NH, 03062 US

Same Address as Manufacturer

CAGE Code: 57034

Phone: 603-879-3268 Fax: 603-879-2818

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE 10-020582, VQE-06-010054, VQE-09-017008, VQE-12-023765, VQE-15-029690, VQE-97-000649

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 24" x 42" Max. Number of Layers: 33 Max. Board Thickness: .25"

Min. Hole Size: .007" Laser Ablated Plated Hole Size Before Plating, .0098" Drilled Plated-Through Hole Before Plating

Aspect Ratio: .6:1 Microvia, 11:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Foil Lamination, Press Fit Mounting, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE 10-020582, VQE-06-010054, VQE-09-017008, VQE-12-023765, VQE-15-029626, VQE-97-000649

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 30" x 36" Max. Number of Layers: 28 Max. Board Thickness: .18"

Min. Hole Size: .006" Laser Ablated Plated Hole Size Before Plating, .0118" Drilled Plated-Through Hole Before Plating

Aspect Ratio: .8:1 Microvia, 11:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Foil Lamination, Press Fit Mounting, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE 10-020582, VQE-06-010054, VQE-09-017008, VQE-12-023765, VQE-15-029690

Composition: M - Mixed based material printed boards, S - Homogenous thermosetting base material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 24" x 31"

Max. Number of Layers: 12

Max. Board Thickness: .101"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.2:1 Through-Hole
Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Permanganate Desmear, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate

Hole Fill/Via Plug: Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Foil Lamination, Press Fit Mounting, Sequential Lamination

MANUFACTURER INFORMATION:

Amphenol Printed Circuits

91 Northeastern Boulevard, Nashua, NH, 03062 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 57034

Phone: 603-879-3268 Fax: 603-879-2818

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-10-019533, VQE-12-023765, VQE-15-029690 Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 24" x 36"

Max. Number of Layers: 4 (types 1, 2, and 3 only)

Max. Board Thickness: .035" Min. Hole Size: .0145"

Aspect Ratio: 1.75:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Palladium-based Copper Plating: Direct Current Plate, Pulse Plate Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb Flex Usage: Use A (Flex During Installation)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-10-019533, VQE-12-023765, VQE-15-029690

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 24" x 49" Max. Number of Layers: 22 Max. Board Thickness: .14"

Min. Hole Size: .0145" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7.75:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Foil Lamination, Press Fit Mounting, Sequential Lamination

Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION:

Calumet Electronics Corp.

25830 Depot Street, Calumet, MI, 49913-1985 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 65337

Phone: 906-337-1305 Fax: 906-337-5359

EMail: quality@calumetelectronics.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE 12 023734, VQE-03-4657, VQE-04-6280, VQE-14-027692 Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 21" x 24"

Max. Number of Layers: 14

Max. Board Thickness: .125"

Min. Hole Size: .016" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL

Additional Fab Capabilities: Press Fit Mounting

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE 12 023734, VQE-03-4657, VQE-04-6280, VQE-13-026419

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 21" x 24"

Max. Number of Layers: 14

Max. Board Thickness: .125"

Min. Hole Size: .016" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL

MANUFACTURER INFORMATION:

Cirexx International, Inc.

791 Nuttman Street, Santa Clara, CA, 95054 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 4MEG7

Phone: 408-988-3980 Fax: 408-988-4534

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQ(VQE-08-016602), VQE-14-028536

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 12" x 18" Max. Number of Layers: 22 Max. Board Thickness: .125"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 12.5:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL

Additional Fab Capabilities: Foil Lamination
Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-08-016602), VQE-14-028536

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18" Max. Number of Layers: 22 Max. Board Thickness: .125"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 12.5:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQ(VQE-07-014176), VQ(VQE-15-029356)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 12" x 18" Max. Number of Layers: 5 Max. Board Thickness: .056"

Min. Hole Size: .046" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1.2:1 Through-Hole
Min. Conductor Width/Space: .0058"/.01"

Hole Preparation: Permanganate Etchback, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: HASL

Additional Fab Capabilities: Blind Vias, Sequential Lamination Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 4MEG7

Cirexx International. Inc.

791 Nuttman Street, Santa Clara, CA, 95054 US

Same Address as Manufacturer

Phone: 408-988-3980 408-988-4534 Fax:

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQ(VQE-08-016602), VQE-14-028536

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .125"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 12.5:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 6T499

Colonial Circuits. Inc.

1026 Warrenton Road, Fredericksburg, VA, 22406-6200

LIC

PLANT LOCATION: CAGE Code: 6T49
Same Address as Manufacturer

Phone: 540-753-5511, x125

Fax: 540-752-2109

EMail: quality@colonialcircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-04-6002

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .088"

Min. Hole Size: .021" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 4.2:1 Through-Hole Min. Conductor Width/Space: .006"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-04-6002

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 12 Max. Board Thickness: .127" Min. Hole Size: .015"

Aspect Ratio: 8.5:1 Through-Hole
Min. Conductor Width/Space: .008"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/5, MIL-PRF-31032/6 Qualification Letters: VQE-04-6002, VQE-06-010192

Rigid Base Material: Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 12" x 18" Max. Number of Layers: 8 Max. Board Thickness: .09"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6.2:1 Through-Hole
Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 6T499

Colonial Circuits. Inc.

1026 Warrenton Road, Fredericksburg, VA, 22406-6200

Same Address as Manufacturer

Phone: 540-753-5511, x125 Fax: 540-752-2109

EMail: quality@colonialcircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQ (VQE-10-019425

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 10 Max. Board Thickness: .093" Min. Hole Size: .01"

Aspect Ratio: 8.6:1 Through-Hole Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

Flex Usage: Use A (Flex During Installation),

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-04-6002

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 12" x 18" Max. Number of Layers: 10 Max. Board Thickness: .093"

Min. Hole Size: .025" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 3.7:1 Through-Hole Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

Flex Usage: Use A (Flex During Installation),

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/6 Qualification Letters: VQE-04-6002

Rigid Base Material: GT: Woven E-Glass, PTFE Resin; GT: Woven E-Glass, PTFE Resin; GX: Glass Base, Woven, Polytetrafluoroethylene Resin, Flame

Resistant; With or without woven or non-woven E-glass, Polytetrafluoroethylene (PTFE) resin, ceramic filler

Max. Panel Size: 12" x 18" Max. Number of Lavers: 2 Max. Board Thickness: .031"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1.55:1 Through-Hole Min. Conductor Width/Space: .025"/.01" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

MANUFACTURER INFORMATION:

Compunetics Inc.

700 Seco Rd, Monroeville, PA, 15146 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 30598

Phone: 412-858-1272

Fax:

EMail: lhart@compunetics.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-13-026082), VQ(VQE-15-029422) Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 32 Max. Board Thickness: .26"

Min. Hole Size: .0098" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10.8:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Periodic Reverse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-15-029722

Composition: M - Mixed based material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant: Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .177"

Min. Hole Size: .017"

Aspect Ratio: 10.4:1 Through-Hole Min. Conductor Width/Space: .0047"/.006" Hole Preparation: Plasma Desmear Copper Plating: Periodic Reverse Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Sequential Lamination

MANUFACTURER INFORMATION:

Cosmotronic. Inc.

16721 Noyes Avenue, Irvine, CA, 92606-5176 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 63695

Phone: 949-660-0740 Fax: 949-553-8371

EMail: Patricia_Alcantar@cosmotronic.co

m

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-04-006966, VQE-05-009107, VQE-06-010085, VQE-06-011248

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"

Max. Board Thickness: .335"

Min. Hole Size: .014" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole
Min. Conductor Width/Space: .005"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Sequential Lamination

Controlled Impedance: Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-04-006966, VQE-05-009107, VQE-06-010085, VQE-06-011248

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"

Max. Board Thickness: .335"

Min. Hole Size: .014" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole
Min. Conductor Width/Space: .005"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Sequential Lamination

Controlled Impedance: Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-04-006966, VQE-05-009107, VQE-06-010085

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant; GM: Glass Base,

Woven, Triazine and/or Bismaleimide Modified Epoxy Resin, Flame Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24"

Max. Number of Layers: 22

Max. Board Thickness: .165"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .006"/.008"

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION:

Cosmotronic, Inc.

16721 Noyes Avenue, Irvine, CA, 92606-5176 US

PLANT LOCATION: CAGE Code: 63695
Same Address as Manufacturer

Phone: 949-660-0740 Fax: 949-553-8371

EMail: Patricia_Alcantar@cosmotronic.co

m

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-04-006966, VQE-05-009107, VQE-06-010085

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant; GM: Glass Base,

Woven, Triazine and/or Bismaleimide Modified Epoxy Resin, Flame Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24"
Max. Number of Layers: 22
Max. Board Thickness: .165"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .006"/.008"
Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/5, MIL-PRF-31032/6

Qualification Letters: VQE-04-006966, VQE-05-009107, VQE-06-010085 Composition: S - Homogenous thermosetting base material printed boards

Rigid Base Material: Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 12" x 18"

Max. Number of Layers: 16

Max. Board Thickness: .225"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole
Min. Conductor Width/Space: .011"/.007"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Sequential Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/5, MIL-PRF-31032/6

Qualification Letters: VQE-04-006966, VQE-05-009107, VQE-06-010085 Composition: S - Homogenous thermosetting base material printed boards

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant; Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 12" x 18" Max. Number of Layers: 16 Max. Board Thickness: .225"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole
Min. Conductor Width/Space: .011"/.007"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Sequential Lamination

MANUFACTURER INFORMATION: PLANT LOCATION:

Dynamic & Proto Circuits, Inc.

869 Barton Street, Stoney Creek, L8E 5G6, Ontario

Canada

Same Address as Manufacturer

CAGE Code: 38898

Phone: 905-643-9900 Fax: 905-643-9911

EMail: dynamicinfo@dapc.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-00-0007, VQE-01-0311, VQE-03-0818, VQE-98-1143

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 16" x 18" Max. Number of Layers: 16 Max. Board Thickness: .125"

Min. Hole Size: .0135" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9.3:1 Through-Hole Min. Conductor Width/Space: .005"/.005" Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Solder Resist: Dry Film, Liquid Photoimageable

Finish System: HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-024252

Rigid Base Material: Gl: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 16" x 18" Max. Number of Layers: 16 Max. Board Thickness: .125"

Min. Hole Size: .0135" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9.3:1 Through-Hole Min. Conductor Width/Space: .025"/.025" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Solder Resist: Dry Film, Liquid Photoimageable

Finish System: HASL

MANUFACTURER INFORMATION:

Electro Plate Circuitry, Inc.

1430 Century Drive, Carrollton, TX, 75006 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 79616

Phone: 972-466-0818 Fax: 972-466-9078 EMail: jimm@eplate.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-06-010333), VQ(VQE-06-011433), VQ(VQE-10-020352)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 16", 18" x 24"

Max. Number of Layers: 14 Max. Board Thickness: .12"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9.3:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable Finish System: ENIG, Electrolytic Ni / Hard Au. HASL

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-06-010333), VQ(VQE-06-011433), VQ(VQE-10-020352)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 16", 18" x 24"

Max. Number of Layers: 18 Max. Board Thickness: .17"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9.3:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable Finish System: ENIG, Electrolytic Ni / Hard Au, HASL

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 79616 Same Address as Manufacturer

Electro Plate Circuitry. Inc.

1430 Century Drive, Carrollton, TX, 75006 US

Phone: 972-466-0818 972-466-9078 Fax: EMail: jimm@eplate.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/5, MIL-PRF-31032/6

Qualification Letters: VQ(VQE-10-021161)

Rigid Base Material: GT: Woven E-Glass, PTFE Resin; GX: Glass Base, Woven, Polytetrafluoroethylene Resin, Flame Resistant; GY: Glass Base, Woven, Polytetrafluoroethylene Resin, Flame Resistant, for Microwave Application, With or without woven or non-woven E-glass, Polytetrafluoroethylene (PTFE)

resin, ceramic filler

Max. Panel Size: 12" x 18", 18" x 24"

Max. Number of Layers: 6 Max. Board Thickness: .18"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6:1 Through-Hole

Min. Conductor Width/Space: .004"/.004" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 66030

Electrotek Corp.

7745 S. 10th Street, Oak Creek, WI, 53154 US

Same Address as Manufacturer

Phone: 414-762-1390 Fax: 414-762-1510

EMail: sales@boards4u.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-06-011451), VQ(VQE-08-014513), VQ(VQE-09-018692), VQ(VQE-12-024024), VQ(VQE-12-024011)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .115"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole

Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: Carbon Ink, ENIG, Electrolytic Ni/Au, HASL, ImmAg

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-06-011451), VQ(VQE-08-014513), VQ(VQE-09-018692), VQ(VQE-12-024024), VQ(VQE-12-024011)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .115"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole

Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: Carbon Ink, ENIG, Electrolytic Ni/Au, HASL, ImmAg

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

MANUFACTURER INFORMATION:

Firan Technology Group

250 Finchdene Square, Scarborough, M1X 1A5, Ontario

Canada

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: L2665

Phone: 416-299-4000
Fax: 416-292-4308
EMail: info@ftgcorp.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-05-009339, VQE-06-010764, VQE-06-010889, VQE-15-028987

Rigid Base Material: BI: Aramid Fabric, Nonwoven, Polyimide Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .101"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6.9:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-05-009339, VQE-06-010764, VQE-06-010889, VQE-15-028987

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .22"

Min. Hole Size: .0059" Laser Ablated Plated Hole Size Before Plating, .0096" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1.01:1 Microvia, 10.2:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-05-009339, VQE-06-010764, VQE-06-010889, VQE-15-028987

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .13"

Min. Hole Size: .0059" Laser Ablated Plated Hole Size Before Plating, .016" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5.6:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

MANUFACTURER INFORMATION: PLA

Firan Technology Group

250 Finchdene Square, Scarborough, M1X 1A5, Ontario

Canada

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: L2665

Phone: 416-299-4000
Fax: 416-292-4308
EMail: info@ftgcorp.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-05-009339, VQE-06-010764, VQE-06-010889, VQE-15-028987

Rigid Base Material: GM: Glass Base, Woven, Triazine and/or Bismaleimide Modified Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .097"

Min. Hole Size: .023" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 3.4:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-15-029018

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 12" x 18" Max. Number of Layers: 12 Max. Board Thickness: .086"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1

Min. Conductor Width/Space: .004"/.004" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 30803 Same Address as Manufacturer

FTG Circuits, Inc. (Chatsworth) 20750 Marilla Street, Chatsworth, CA, 91311 US Fax:

Phone: 818-407-4024 818-407-4034 EMail: info@ftgcorp.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-16-030066

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 28 Max. Board Thickness: .2"

Min. Hole Size: .006" Laser Ablated Plated Hole Size Before Plating, .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1.1:1 Microvia, 10:1 Through-Hole Min. Conductor Width/Space: .0035"/.004"

Hole Preparation: Permanganate Etchback, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION:

Gorilla Circuits

1445 Old Oakland Rd, San Jose, CA, 95112 US

CAGE Code: 3C7D2

Phone: 408-294-9897

Fax: 408-297-1540

EMail: info@gorillacircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: 11-022314, 14-028138

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .18"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 18:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate
Hole Fill/Via Plug: Non-Conductive
Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL Additional Fab Capabilities: Blind Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: 11-022314, 14-028138

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .093"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating, .01" Laser Ablated Plated Hole Size Before Plating

Aspect Ratio: 1:1 Microvia, 9.3:1 Through-Hole Min. Conductor Width/Space: .004"/.005" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL

Additional Fab Capabilities: Blind Vias

MANUFACTURER INFORMATION:

Graphic Plc

Lords Meadow Industrial Estate, Crediton, Devon, EX17

IHN UK

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: U4538

Phone: 44-1363-774874 Fax: 44-1363-772265

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-11-023205, VQE-12-025118

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 12" x 18" Max. Number of Layers: 10

Max. Board Thickness: .11" (2.79mm)

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.4:1 Through-Hole Min. Conductor Width/Space: .004"/.004" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Foil Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-025119

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18"

Max. Number of Layers: 10

Max. Board Thickness: .11" (2.79mm)

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.4:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Foil Lamination

MANUFACTURER INFORMATION:

Hamby Corporation

27704 Avenue Scott, Valencia, CA, 91355-1218 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 07284

Phone: 661-257-1924 Fax: 661-257-1213

EMail: suesharp@hambycorp.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-09-017349

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 12" x 18"

Max. Number of Layers: 6

Max. Board Thickness: .035"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 2:1 Through-Hole

Min. Conductor Width/Space: .009"/.009"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: Electrolytic Ni / Hard Au, HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-08-14596

Rigid Base Material: Gl: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 11 Max. Board Thickness: .085"

Min. Hole Size: .018" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: Electrolytic Ni / Hard Au, HASL Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-09-017349

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18" Max. Number of Layers: 6 Max. Board Thickness: .035"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 2:1 Through-Hole

Min. Conductor Width/Space: .009"/.009"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: Electrolytic Ni / Hard Au, HASL

PLANT LOCATION: MANUFACTURER INFORMATION: Same Address as Manufacturer

Hamby Corporation

27704 Avenue Scott, Valencia, CA, 91355-1218 US

CAGE Code: 07284

Phone: 661-257-1924 661-257-1213 Fax:

EMail: suesharp@hambycorp.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-08-14596

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24" Max. Number of Layers: 11 Max. Board Thickness: .095"

Min. Hole Size: .018" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: Electrolytic Ni / Hard Au, HASL Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: C4831

Hans Brockstedt GmbH

Clara-Immerwahr-Strabe 7, 24145 Kiel Germany

PLANT LOCATION: CAGE Code: C483
Same Address as Manufacturer

Phone: 0049-431-71966-0, -30
Fax: 0049-431-71966-29
EMail: klammer@brockstedt.de

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-03-2619, VQE-05-7480

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 9" x 13", 13" x 20", 15" x 21", 18" x 24"

Max. Number of Layers: 12 Max. Board Thickness: .2"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 7:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4 Qualification Letters: VQE-03-2619, VQE-05-7480,

Composition: S - Homogenous thermosetting base material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 9" x 13", 13" x 20"
Max. Number of Layers: 12
Max. Board Thickness: .2"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 7:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3

Qualification Letters: VQE-03-2619, VQE-05-7480, VQE-13-25594 Composition: S - Homogenous thermosetting base material printed boards

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 9" x 13", 13" x 20"

Max. Number of Layers: 2
Max. Board Thickness: .01"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Through-Hole Min. Conductor Width/Space: .004"/.004" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: C4831

Hans Brockstedt GmbH

Clara-Immerwahr-Strabe 7, 24145 Kiel Germany

Same Address as Manufacturer CAGE Code: C483

Phone: 0049-431-71966-0, -30
Fax: 0049-431-71966-29
EMail: klammer@brockstedt.de

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-03-2619, VQE-05-7480

Rigid Base Material: Gl: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 9" x 13", 13" x 20", 15" x 21", 18" x 24"

Max. Number of Layers: 12 Max. Board Thickness: .2"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 7:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination

MANUFACTURER INFORMATION:

Holaday Circuits, Inc.

11126 Bren Road West, Minnetonka, MN, 55343 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 59554

Phone: 952-988-8059

Fax:

EMail: MarwanR@Holaday.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-15-028707)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .11"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7.8:1 Through-Hole
Min. Conductor Width/Space: .003"/.0037"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate

Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable Finish System: ENIG, HASL, ImmAq, OSP

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION:

Hughes Circuits, Inc.

540 S. Pacific Street, San Marcos, CA, 92078-4056 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 1KXU6

Phone: 760-744-0300 Fax: 760-744-6388

EMail: joe@hughescircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-08-015865), VQ(VQE-14-028093), VQE-12-24783

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .08"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole

Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Graphite-based Copper Plating: Direct Current Plate, Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-07-014018), VQ(VQE-14-028093), VQE-12-24783 Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 10 Max. Board Thickness: .08"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole

Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Graphite-based Copper Plating: Direct Current Plate, Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

PLANT LOCATION: MANUFACTURER INFORMATION: Same Address as Manufacturer

ISU Petasys

12930 Bradley St., Sylmar, CA, 91342 US

CAGE Code: 1WFH9

Phone: 818-833-4832

Fax:

EMail: SimeonR@isupetasys.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-15-028813)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .15" Min. Hole Size: .0098"

Aspect Ratio: 12.5:1 Through-Hole Min. Conductor Width/Space: .003"/.004"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate, Periodic Reverse Plate

Solder Resist: Liquid Photoimageable

Finish System: ImmAg

Additional Fab Capabilities: Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION:

KCA Electronics. Inc.

223 N. Crescent Way, Anaheim, CA, 92801 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 1VUH8

Phone: 714-239-2433 Fax: 714-239-2455

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-11-022964, VQE-14-027414, VQE-16-030045 Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .117"

Min. Hole Size: .0135" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.67:1 Through-Hole Min. Conductor Width/Space: .0098"/.0044"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4 Qualification Letters: VQE-11-021796, VQE-14-027414

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 12" x 18" Max. Number of Layers: 16 Max. Board Thickness: .074"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole
Min. Conductor Width/Space: .005"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: HASL

Additional Fab Capabilities: Blind Vias, Sequential Lamination

Controlled Impedance: Differential Flex Usage: Use A (Flex During Installation)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3 Qualification Letters: VQE-11-021796

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 12" x 18" Max. Number of Layers: 1 Max. Board Thickness: .008"

Min. Conductor Width/Space: .004"/.006"

Finish System: HASL

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: Same Address as Manufacturer

KCA Electronics. Inc.

223 N. Crescent Way, Anaheim, CA, 92801 US

CAGE Code: 1VUH8

Phone: 714-239-2433 714-239-2455 Fax:

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-11-022398, VQE-14-027414

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .092"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .0079" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 0.75:1 Microvia, 7:1 Through-Hole Min. Conductor Width/Space: .0048"/.004"

Hole Preparation: Permanganate Etchback, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: HASL

MANUFACTURER INFORMATION:

Lockheed Martin Mission Systems & Training 1801 State Route 17C, Owego, NY, 13827 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 03640

Phone: 607-751-5395 Fax: 607-751-7714

EMail: renee.akers@lmco.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-00-000961, VQE-15-029009, VQE-15-029561, VQE-99-000130 Rigid Base Material: AF: Aramid Fabric, Woven, Majority Polyfunctional Epoxy Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .075"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 3.6:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-01-0539, VQE-15-029009, VQE-15-029561 Rigid Base Material: BI: Aramid Fabric, Nonwoven, Polyimide Resin

Max. Panel Size: 18" x 24" Max. Number of Layers: 14 Max. Board Thickness: .095"

Min. Hole Size: .014" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6.8:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-00-000961, VQE-07-013268, VQE-07-013459, VQE-11-022596, VQE-15-029009, VQE-15-029561, VQE-99-000130

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 24" x 30"

Max. Number of Layers: 24

Max. Board Thickness: .104"

Min. Hole Size: .018" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

MANUFACTURER INFORMATION:

Lockheed Martin Mission Systems & Training 1801 State Route 17C, Owego, NY, 13827 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 03640

Phone: 607-751-5395 Fax: 607-751-7714

EMail: renee.akers@lmco.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-00-000961, VQE-07-013459, VQE-15-029009, VQE-15-029561, VQE-99-000130

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 24" x 30" Max. Number of Layers: 16 Max. Board Thickness: .082"

Min. Hole Size: .018" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-00-000684, VQE-07-013459, VQE-15-029009

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .11"

Min. Hole Size: .016" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb

Flex Usage: Use A (Flex During Installation)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-00-000684, VQE-07-013459, VQE-15-029009, VQE-15-029562

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 12" x 18"

Max. Number of Layers: 4 (types 1, 2, and 3 only)

Max. Board Thickness: .022" Min. Hole Size: .0413" Aspect Ratio: .5:1 Through-Hole

Min. Conductor Width/Space: .009"/.01"

Hole Preparation: Permanganate Desmear, Permanganate Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb

Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION:

Lone Star Circuits

901 Hensley Drive, Wylie, TX, 75098-4909 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 04RV5

Phone: 214-291-1427

Fax:

EMail: sdiacont@lscpwb.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-4341, VQE-04-5599, VQE-04-5891, VQE-05-7288 Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .119"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7.5:1 Through-Hole Min. Conductor Width/Space: .004"/.005"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, Fused Tin Lead, HASL, Hot Oil Reflow of Plated Sn/Pb, ImmAg

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-04-4957, VQE-05-7288

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 12 Max. Board Thickness: .074"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6.2:1 Through-Hole Min. Conductor Width/Space: .007"/.007" Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, Fused Tin Lead, HASL, Hot Oil Reflow of Plated Sn/Pb, ImmAg

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/6 Qualification Letters: VQE-11-021947

Rigid Base Material: GY: Glass Base, Woven, Polytetrafluoroethylene Resin, Flame Resistant, for Microwave Application

Max. Panel Size: 18" x 24" Max. Number of Layers: 2 Max. Board Thickness: .031"

Min. Hole Size: .039" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Through-Hole Min. Conductor Width/Space: .19"/.9515" Hole Preparation: Sodium Treatment

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: ENIG, Electrolytic Ni / Hard Au, Fused Tin Lead, HASL, Hot Oil Reflow of Plated Sn/Pb, ImmAg

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 34076 Same Address as Manufacturer

Micom Corp.

475 Old Highway 8 NW, New Brighton, MN, 55112 US

Phone: 651-604-2625 Fax: 651-636-1352

EMail: dboley@micomcircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-02-002780, VQE-03-002980, VQE-12-023661 Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 28 Max. Board Thickness: .239"

Min. Hole Size: .007" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Embedded Resistors, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-02-002780, VQE-03-002980, VQE-12-023661 Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 28 Max. Board Thickness: .239"

Min. Hole Size: .007" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION:

Midwest Printed Circuit Services

1741 Circuit Drive, Round Lake Beach, IL, 60073 US

CAGE Code: 0YYS4

Phone: 847-740-4120

Fax: 847-740-4187

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-13-025705, VQE-14-028088

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .1"

Min. Hole Size: .038" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 2.5:1 Through-Hole Min. Conductor Width/Space: .01"/.01"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable Finish System: ENIG, HASL

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-024841, VQE-12-025070, VQE-13-025727, VQE-14-028088

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 12
Max. Board Thickness: .1"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7.92:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Controlled Depth Mechanically Drilled Low Aspect Ratio Blind Vias, Foil Lamination

Controlled Impedance: Differential

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE O

Murrietta Circuits, Inc.

5000 E. Landon Drive, Anaheim, CA, 92807 US

Same Address as Manufacturer

CAGE Code: 0EJD7 Phone: 714-970-2430

Fax: 714-970-2406 EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-15-029521

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"

Max. Number of Layers: 12

Max. Board Thickness: .103"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Etchback, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Single-Ended

MANUFACTURER INFORMATION: CAGE Code: 65723 Pioneer Circuits. Inc. Phone: 714-641-3132 3000 S. Shannon Street, Santa Ana, CA, 92704-6321 US Fax: 714-641-3120

EMail: Quality@pioneercircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-09-017323, VQE-09-017656

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 22 Max. Board Thickness: .177"

Min. Hole Size: .0135" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole

Min. Conductor Width/Space: .0035"/.0035"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate, Periodic Reverse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-09-017323, VQE-09-017656

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .275"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole

Min. Conductor Width/Space: .0035"/.0035"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate, Periodic Reverse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

MANUFACTURER INFORMATION:

Pioneer Circuits, Inc.

3000 S. Shannon Street, Santa Ana, CA, 92704-6321 US

CAGE Code: 65723

Phone: 714-641-3132

Fax: 714-641-3120

EMail: Quality@pioneercircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-09-017323, VQE-09-017656, VQE-10-029651 Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 26"
Max. Number of Layers: 22
Max. Board Thickness: .231"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.5:1 Through-Hole
Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Periodic Reverse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4 Qualification Letters: VQE-09-017323, VQE-09-017656

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .1"

Min. Hole Size: .016" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6:1 Through-Hole

Min. Conductor Width/Space: .0035"/.0035"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Periodic Reverse Plate

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 $\label{eq:hole Fill-Via Plug: Conductive} Hole \ Fill-Via \ Plug: \ Conductive, \ Non-Conductive$

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Book Binder, Buried Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION:

Pioneer Circuits, Inc.

3000 S. Shannon Street, Santa Ana, CA, 92704-6321 US

CAGE Code: 65723

Phone: 714-641-3132

Fax: 714-641-3120

EMail: Quality@pioneercircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4 Qualification Letters: VQE-09-017323, VQE-09-017656

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 24" x 36" Max. Number of Layers: 26 Max. Board Thickness: .185"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole

Min. Conductor Width/Space: .0035"/.0035"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate, Periodic Reverse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Book Binder, Buried Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

PLANT LOCATION: MANUFACTURER INFORMATION: CAGE Code: 66766 PNC. Inc.

115 East Centre Street, Nutley, NJ, 07110 US

Same Address as Manufacturer Phone: 973-284-1600

Fax:

EMail: carmela@pnconline.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-10-19440, VQE-15-029233

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 16 Max. Board Thickness: .12"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole Min. Conductor Width/Space: .003"/.003" Hole Preparation: Permanganate Desmear Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Differential

MANUFACTURER INFORMATION:

Printed Circuits. Inc.

1200 West 96th Street, Bloomington, MN, 55431-2606 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 65114

Phone: 952-886-9333

Fax:

EMail: jsmith@printedcircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-15-029290)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 12" x 18", 18" x 24"

Max. Number of Layers: 16
Max. Board Thickness: .12"
Min. Hole Size: .01"
Aspect Ratio: 10:1

Min. Conductor Width/Space: .004"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Carbon-based Copper Plating: Direct Current Plate, Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-15-029290)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18", 18" x 24"

Max. Number of Layers: 16 Max. Board Thickness: .12" Min. Hole Size: .01"

Aspect Ratio: 10:1

Min. Conductor Width/Space: .004"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Carbon-based Copper Plating: Direct Current Plate, Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-01-000024

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 12" x 18", 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .12"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole Min. Conductor Width/Space: .004"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Sequential Lamination

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION:

Pro-Tech Interconnect Solutions LLC

4300 Peavey Road, Chaska, MN, 55318 US

CAGE Code: 3CP65

Phone: 952-442-2189

Fax: 952-442-2472

EMail: hkooda@protechmn.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-11-021704

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .1"

Min. Hole Size: .024" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 4:1 Through-Hole

Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Carbon-based

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg, OSP

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-11-021704, VQE-16-030058

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .1"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .0059" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .003"/.002"

Hole Preparation: Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Carbon-based

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, ImmAg, OSP Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

MANUFACTURER INFORMATION:

Sanmina-SCI (Costa Mesa)

2945 Airway Avenue, Costa Mesa, CA, 92626 US

CAGE Code: 3BKL5

Phone: 714-371-2800

Fax: 714-371-2833

EMail: joann.medina@sanmina-sci.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-024031

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 12" x 18" Max. Number of Layers: 8 Max. Board Thickness: .063"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 5:1 Through-Hole Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable Finish System: Electrolytic Ni / Soft Au, HASL

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Press Fit Mounting, Sequential Lamination

Controlled Impedance: Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-12-24471

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18"

Max. Number of Layers: 18

Max. Board Thickness: .093"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7: 1 Through-Hole

Min. Conductor Width/Space: .003"/.0035"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate
Hole Fill/Via Plug: Non-Conductive
Solder Resist: Liquid Photoimageable
Finish System: Electrolytic Ni / Soft Au, HASL
Additional Fab Capabilities: Foil Lamination
Controlled Impedance: Single-Ended

MANUFACTURER INFORMATION: CAGE Code: 4GZ84 Sanmina-SCI (Owego) Phone: 607-689-5543

1200 Taylor Rd., Owego, NY, 13827 US Fax:

EMail: rick.sylvain@sanmina-sci.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-11-21597

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 12 Max. Board Thickness: .11"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9.3:1 Through-Hole Min. Conductor Width/Space: .008"/.0045" Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: HASL

Additional Fab Capabilities: Foil Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-11-22386

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .095"

Min. Hole Size: .007" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: .59:1 Microvia, 9.7:1 Through-Hole Min. Conductor Width/Space: .0035"/.0032"

Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Pulse Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: HASL

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Cod

Sanmina-SCI (San Jose)

2050 Bering Drive, San Jose, CA, 95131 US

Same Address as Manufacturer

CAGE Code: 3DR67

Phone: 408-964-6515 Fax: 408-964-6453

EMail: darrell.myers@sanmina-sci.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-06-11137, VQE-10-19381, VQE-11-22038

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 21" x 27"
Max. Number of Layers: 30
Max. Board Thickness: .25"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 14:1 Through-Hole Min. Conductor Width/Space: .003"/.003" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb, ImmAg, OSP Additional Fab Capabilities: Buried Vias. Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-06-11137

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 30
Max. Board Thickness: .25"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole, 1:2 Microvia Min. Conductor Width/Space: .003"/.003" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/2, MIL-PRF-31032/6 Qualification Letters: VQE-10-20921, VQE-10-21014

Rigid Base Material: Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 21" x 24"
Max. Number of Layers: 2
Max. Board Thickness: .062"

Min. Hole Size: .0197" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 3.1:1 Through-Hole
Min. Conductor Width/Space: .008"/.014"
Hole Wall Conductive Coating: Electroless Copper
Copper Plating: Direct Current Plate, Pulse Plate
Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG

MANUFACTURER INFORMATION: PLANT LOCATION:

Sanmina-SCI (San Jose)

2050 Bering Drive, San Jose, CA, 95131 US

Same Address as Manufacturer

CAGE Code: 3DR67

Phone: 408-964-6515 Fax: 408-964-6453

EMail: darrell.myers@sanmina-sci.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/5

Qualification Letters: VQE-11-021514

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 21" x 24" Max. Number of Layers: 7 Max. Board Thickness: .066"

Min. Hole Size: .01"

Aspect Ratio: 7:1 Through-Hole

Min. Conductor Width/Space: .005"/.004" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable Finish System: ENIG

Additional Fab Capabilities: Blind Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Rigid Base Material: BI: Aramid Fabric, Nonwoven, Polyimide Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 12
Max. Board Thickness: .088"
Min. Hole Size: .0138"

Aspect Ratio: 5.4:1 Through-Hole

Min. Conductor Width/Space: .0064"/.0068" Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG

MANUFACTURER INFORMATION:

Speedy Circuits, Inc.

5331 McFadden Avenue, Huntington Beach, CA, 92649-

1204 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 66982

Phone: 714-898-4901 Fax: 714-891-0607

EMail: sales@speedycircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-08-016434, VQE-10-021007

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .11"

Min. Hole Size: .015" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole

Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: Electrolytic Ni (no Au), HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Foil Lamination
Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-08-016434, VQE-10-021007

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .11"

Min. Hole Size: .015" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole
Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-08-016434, VQE-10-019157, VQE-10-021007 Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .13"

Min. Hole Size: .002" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole
Min. Conductor Width/Space: .005"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 66982

Speedy Circuits, Inc.

5331 McFadden Avenue, Huntington Beach, CA, 92649-

1204 US

Same Address as Manufacturer Phone: 714-898-4901
Fax: 714-891-0607

EMail: sales@speedycircuits.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/6 Qualification Letters: VQE-08-016434

Composition: H - Homogenous thermoplastic base material printed boards

Rigid Base Material: GR: Glass Base, Nonwoven, Polytetrafluoroethylene Resin, Flame Resistant; GY: Glass Base, Woven, Polytetrafluoroethylene Resin,

Flame Resistant, for Microwave Application

Max. Panel Size: 12" x 18" Max. Number of Layers: 2 Max. Board Thickness: .036"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 2:1 Through-Hole
Min. Conductor Width/Space: .005"/.005"
Hole Wall Conductive Coating: Electroless Copper
Copper Plating: Direct Current Plate

Finish System: Hot Oil Reflow of Plated Sn/Pb

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/5, MIL-PRF-31032/6

Qualification Letters: VQE-09-018657

Composition: M - Mixed based material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; With or without woven or non-woven E-glass, Polytetrafluoroethylene (PTFE)

resin, ceramic filler
Max. Panel Size: 12" x 18"

Max. Number of Layers: 10 Woven E-Glass, Hydrocarbon Resin, Ceramic Filler - Homogenous

Max. Board Thickness: .1"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole Min. Conductor Width/Space: .005"/.005" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/5, MIL-PRF-31032/6

Qualification Letters: VQE-09-018657

Composition: S - Homogenous thermosetting base material printed boards

Rigid Base Material: Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 12" x 18"

Max. Number of Layers: 10 With or Without Woven or Non-woven E-Glass, PTFE Resin, Ceramic Filler and Woven E-Glass, Epoxy Resin - Mixed

Max. Board Thickness: .068"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6:1 Through-Hole
Min. Conductor Width/Space: .005"/.005"
Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb

MANUFACTURER INFORMATION: **Teledyne Printed Circuit Technology**110 Lowell Road, Hudson, NH, 03051 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 22958

Phone: 603-889-6191

Fax:

EMail: pctsales@teledyne.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-15-029796

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24" Max. Number of Layers: 30 Max. Board Thickness: .225" Min. Hole Size: .0295"

Aspect Ratio: 7.5:1 Through-Hole Min. Conductor Width/Space: .004"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-15-029796

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 24" x 30" Max. Number of Layers: 7 Max. Board Thickness: .06"

Min. Hole Size: .035" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1.8:1 Through-Hole Min. Conductor Width/Space: .004"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Sequential Lamination Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION:

Thales Nederland B.V.

Haaksbergerstraat 49, 7554PA Hengelo The Netherlands

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: H0203

Phone: 31 0 742482880 Fax: 31 0 742484124

EMail: jan.bokhove@nl.thalesgroup.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-14-028079

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 12" x 18"
Max. Number of Layers: 10
Max. Board Thickness: .1"

Min. Hole Size: .025" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 4:1 Through-Hole

Min. Conductor Width/Space: .005"/.005" Hole Preparation: Permanganate Desmear Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: HASL

Additional Fab Capabilities: Foil Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-14-028079

Rigid Base Material: Gl: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18" Max. Number of Layers: 10 Max. Board Thickness: .1"

Min. Hole Size: .025" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 4:1 Through-Hole

Min. Conductor Width/Space: .005"/.005" Hole Preparation: Permanganate Desmear Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: HASL

Additional Fab Capabilities: Foil Lamination

MANUFACTURER INFORMATION:

TTM Technologies (Santa Ana)

2630 South Harbor Boulevard, Santa Ana, CA, 92704 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 1WQ42

Phone: 714-241-0303 Fax: 714-241-0708

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-05-8644, VQE-06-011211

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 24
Max. Board Thickness: .2"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 14:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb, ImmAg, OSP Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-05-8644, VQE-06-011211, VQE-12-023569 Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 24
Max. Board Thickness: .2"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 14:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb, ImmAg, OSP Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

MANUFACTURER INFORMATION:

TTM Technologies (Santa Clara)

407 Mathew Street, Santa Clara, CA, 95050 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 65916

Phone: 408-486-3184 Fax: 408-727-1003

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-13-026953, VQE-14-028262

Rigid Base Material: BF: Aramid Fabric, Nonwoven, Epoxy Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .076"

Min. Hole Size: .0118" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7:1 Through-Hole

Min. Conductor Width/Space: .0088"/.008"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive Solder Resist: Liquid Photoimageable Finish System: ENIG, HASL

Controlled Impedance: Differential

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003888, VQE-10-020500, VQE-10-020581, VQE-11-022973, VQE-14-028240, VQE-14-028262, VQE-15-029137, VQE-15-029137

029683

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 21.5" x 24.5" Max. Number of Layers: 28 Max. Board Thickness: .19"

Min. Hole Size: .0098" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003888, VQE-10-020500, VQE-10-020581, VQE-11-022973, VQE-14-028240, VQE-14-028262

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 16 Max. Board Thickness: .12"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION:

TTM Technologies (Santa Clara)

407 Mathew Street, Santa Clara, CA, 95050 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 65916

Phone: 408-486-3184 Fax: 408-727-1003

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-03-003895, VQE-10-020500, VQE-10-020581, VQE-11-022973, VQE-14-028240, VQE-14-028262 Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .12"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Sequential Lamination Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-03-003895, VQE-10-020500, VQE-10-020581, VQE-11-022973, VQE-14-028240

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24"
Max. Number of Layers: 6
Max. Board Thickness: .043"

Min. Hole Size: .031" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Finish System: ENIG, HASL

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-07-013211, VQE-11-022973, VQE-14-028240, VQE-14-028262

Composition: H - Homogenous thermoplastic base material printed boards, M - Mixed based material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .109"

Min. Hole Size: .0118" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Etchback, Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Sequential Lamination

MANUFACTURER INFORMATION:

TTM Technologies (Santa Clara)

407 Mathew Street, Santa Clara, CA, 95050 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 65916

Phone: 408-486-3184 Fax: 408-727-1003

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003888, VQE-10-020500, VQE-10-020581, VQE-11-022973, VQE-14-028240, VQE-14-028262

Rigid Base Material: BI: Aramid Fabric, Nonwoven, Polyimide Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .12"

Min. Hole Size: .012" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6.45:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

MANUFACTURER INFORMATION: PLANT LOCATION:

TTM Technologies (Stafford)

4 Old Monson Road, Stafford, CT, 06075 US

Same Address as Manufacturer

CAGE Code: 5L706

Phone: 860-684-5881 Fax: 860-684-7425

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003348, VQE-09-018855, VQE-11-023287, VQE-12-023366

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; Woven E-Glass, Epoxy Resin, Flame Resistant, with Inorganic Filler

Max. Panel Size: 30" x 54" Max. Number of Layers: 50 Max. Board Thickness: .4"

Min. Hole Size: .006" Laser Ablated Plated Hole Size Before Plating, .0079" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 14:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Copper Core, Embedded Resistors, Press Fit Mounting, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003348, VQE-09-018855, VQE-11-023287, VQE-12-023366, VQE-16-030095

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 24" x 36" Max. Number of Layers: 32 Max. Board Thickness: .219"

Min. Hole Size: .0079" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Copper Core, Copper Invar Copper, Embedded Resistors, Press Fit Mounting, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003348, VQE-09-018855, VQE-11-023287, VQE-16-030095 Rigid Base Material: AF: Aramid Fabric, Woven, Majority Polyfunctional Epoxy Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .1"

Min. Hole Size: .0138" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5:1 Through-Hole

Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Foil Lamination, Controlled Impedance: Differential, Single-Ended

MANUFACTURER INFORMATION: PLANT LOCATION:

TTM Technologies (Stafford)

4 Old Monson Road, Stafford, CT, 06075 US

Same Address as Manufacturer

CAGE Code: 5L706

Phone: 860-684-5881 Fax: 860-684-7425

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003348, VQE-09-018855, VQE-11-023287, VQE-12-023366, VQE-16-030095

Rigid Base Material: BI: Aramid Fabric, Nonwoven, Polyimide Resin

Max. Panel Size: 18" x 24"
Max. Number of Layers: 22
Max. Board Thickness: .129"

Min. Hole Size: .0118" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11:1 Through-Hole Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-03-003348, VQE-09-018855, VQE-11-023287

Rigid Base Material: GM: Glass Base, Woven, Triazine and/or Bismaleimide Modified Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .1"

Min. Hole Size: .032" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 3:1 Through-Hole

Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: Custom

Qualification Letters: VQE-03-003348, VQE-10-019855, VQE-11-023287, VQE-16-030095

Rigid Base Material: With or without woven or non-woven E-glass, Polytetrafluoroethylene (PTFE) resin, ceramic filler

Max. Panel Size: 24" x 30" Max. Number of Layers: 16 Max. Board Thickness: .11"

Min. Hole Size: .0098" Drilled Plated-Through Hole Before Plating, .012" Laser Ablated Plated Hole Size Before Plating

Aspect Ratio: .5:1 Microvia, 7.6:1 Through-Hole Min. Conductor Width/Space: .004"/.003" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Embedded Resistors, Sequential Lamination

PLANT LOCATION: MANUFACTURER INFORMATION: Same Address as Manufacturer

TTM Technologies (Stafford)

4 Old Monson Road, Stafford, CT, 06075 US

CAGE Code: 5L706

Phone: 860-684-5881 Fax: 860-684-7425

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2, Custom

Qualification Letters: VQE-03-003348, VQE-10-019855, VQE-11-023287, VQE-16-030095

Composition: M - Mixed based material printed boards

Rigid Base Material: Woven Glass Reinforced, Hydrocarbon Resin with Ceramic Fill

Max. Panel Size: 24" x 42" Max. Number of Layers: 24 Max. Board Thickness: .175"

Min. Hole Size: .006" Laser Ablated Plated Hole Size Before Plating, .0098" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 9:1 Through-Hole Min. Conductor Width/Space: .004"/.003" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Copper Core, Embedded Resistors, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-03-003349, VQE-09-018855, VQE-10-019456, VQE-11-023287, VQE-12-023366, VQE-16-030095

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant; Woven E-Glass,

Epoxy Resin, Flame Resistant, with Inorganic Filler Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 24" x 36" Max. Number of Layers: 24 Max. Board Thickness: .275"

Min. Hole Size: .0079" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole

Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 5L706

TTM Technologies (Stafford) Phone: 860-684-58

Phone: 860-684-5881 Fax: 860-684-7425

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

4 Old Monson Road, Stafford, CT, 06075 US

Qualification Letters: VQE-03-003349, VQE-10-019456, VQE-11-023287

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant; Woven E-Glass,

Epoxy Resin, Flame Resistant, with Inorganic Filler

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24"
Max. Number of Layers: 11
Max. Board Thickness: .07"

Min. Hole Size: .035" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 2:1 Through-Hole
Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable, Silk Screen

Finish System: ENIG, Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination,

Controlled Impedance: Differential, Single-Ended

Flex Usage: Use A (Flex During Installation), Use B (Dynamic Flex)

MANUFACTURER INFORMATION: PLANT LOCATION: CAGE Code: 66311

Unicircuit. Inc.

8192 Southpark Lane, Littleton, CO, 80120 US

PLANT LOCATION: CAGE Code: 6631
Same Address as Manufacturer

Phone: 303-730-0505, x110

Fax:

EMail: blageman@unicircuit.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-07-13789, VQE-09-17422, VQE-11-23044

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 12" x 18"
Max. Number of Layers: 16
Max. Board Thickness: .12"

Min. Hole Size: .006" Laser Ablated Plated Hole Size Before Plating, .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6:1 Through-Hole Min. Conductor Width/Space: .005"/.005" Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-09-17422, VQE-12-24296

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 20" x 26" Max. Number of Layers: 16 Max. Board Thickness: .12"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole Min. Conductor Width/Space: .005"/.005" Hole Preparation: Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb Controlled Impedance: Differential, Single-Ended

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - Anaheim 3140 East Coronado Street, Anaheim, CA, 92806 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 0BSG1

Phone: 714-688-7296

Fax: EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-09-018147), VQ(VQE-14-028542), VQE-14-028660, VQE-16-029908

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 14
Max. Board Thickness: .1"

Min. Hole Size: .02" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5:1 Through-Hole
Min. Conductor Width/Space: .01"/.01"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Foil Lamination Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-09-018147)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 22
Max. Board Thickness: .115"

Min. Hole Size: .009" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole
Min. Conductor Width/Space: .004"/.006"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - Cleveland 7 Ascot Parkway, Cuyahoga Falls, OH, 44223 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 7Z463

Phone: 330-572-3400 Fax: 330-572-3434

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-00-000289, VQE-01-000910, VQE-05-008414, VQE-06-010963, VQE-15-028749

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 12
Max. Board Thickness: .126"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9:1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-00-000289, VQE-01-000910, VQE-05-008414, VQE-06-010963, VQE-15-028749

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 16
Max. Board Thickness: .126"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 5.1 Through-Hole

Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable Finish System: HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-01-000909, VQE-06-010963, VQE-14-027433

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24"
Max. Number of Layers: 7
Max. Board Thickness: .07"

Min. Hole Size: .026" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 2.6:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: HASL

Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - Cleveland 7 Ascot Parkway, Cuyahoga Falls, OH, 44223 US

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 7Z463

Phone: 330-572-3400 Fax: 330-572-3434

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-01-000909, VQE-06-010963, VQE-14-027433, VQE-15-208749

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24"

Max. Number of Layers: 12

Max. Board Thickness: .126"

Min. Hole Size: .013" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: HASL

Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - Denver 10570 Bradford Road, Littleton, CO, 80127-4211 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 75815

Phone: 303-972-4105 Fax: 303-933-2934

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-02-000317, VQE-05-007627, VQE-05-009014, VQE-09-018719, VQE-10-020224, VQE-12-024984, VQE-13-026251, VQE-13-026251

026429. VQE-15-029639

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"

Max. Number of Layers: 24

Max. Board Thickness: .125"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .0098" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-02-000317, VQE-05-007627, VQE-05-009014, VQE-09-018719, VQE-10-020224, VQE-12-024984, VQE-13-026251, VQE-13-026251, VQE-13-026251, VQE-05-009014, VQE-05-009014

026429, VQE-15-029639

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 20
Max. Board Thickness: .14"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .0118" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, Hot Oil Reflow of Plated Sn/Pb

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - North Jackson 12080 DeBartolo Drive, North Jackson, OH, 44451 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 0GN71

Phone: 330-538-3900 Fax: 330-538-3820

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-03-003121), VQ(VQE-03-003214), VQ(VQE-07-012925), VQ(VQE-10-020405)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 24
Max. Board Thickness: .25"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole
Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, ImmAg, Ni/Pd/Au, OSP Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-03-003121), VQ(VQE-03-003214), VQ(VQE-07-012925), VQ(VQE-10-020405)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 24
Max. Board Thickness: .25"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole
Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive Solder Resist: Dry Film, Liquid Photoimageable Finish System: ENIG, HASL, ImmAg, Ni/Pd/Au, OSP

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQ(VQE-03-003121), VQ(VQE-03-003214), VQ(VQE-07-012925), VQ(VQE-10-020405)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 24 Max. Board Thickness: .25"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 15:1 Through-Hole Min. Conductor Width/Space: .003"/.003"

Hole Preparation: Permanganate Desmear, Permanganate Etchback, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni/Au, HASL, ImmAg, OSP Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - San Jose 355 Turtle Creek Court, San Jose, CA, 95125-1316 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 0MHG5

Phone: 408-938-7219 Fax: 408-280-0641

EMail: arnold.amaral@viasystems.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-08-016481), VQ(VQE-08-016632) Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 20
Max. Board Thickness: .13"

Min. Hole Size: .004" Laser Ablated Plated Hole Size Before Plating, .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 0.8:1 Microvia, 10:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate

Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni, Electrolytic Ni / Hard Au, HASL Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-08-016481), VQ(VQE-08-016632)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 20
Max. Board Thickness: .13"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating, .008" Laser Ablated Plated Hole Size Before Plating

Aspect Ratio: 0.8:1 Microvia, 10:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate

Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Hard Au, HASL

Additional Fab Capabilities: Blind Vias, Buried Vias, Sequential Lamination

MANUFACTURER INFORMATION:

Viasystems Technologies Corp., LLC - Sterling 1200 Severn Way, Sterling, VA, 20166-8904 US PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 0K703

Phone: 703-652-2200 Fax: 703-652-2272

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-03-003545), VQ(VQE-09-018207), VQ(VQE-14-028500), VQ(VQE-14-028501)

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 26
Max. Board Thickness: .11"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .009" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: LDI, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni (no Au), Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Resistors

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-03-003545), VQ(VQE-09-018207), VQ(VQE-14-028500), VQ(VQE-14-028501)

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 26
Max. Board Thickness: .11"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .009" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole
Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: LDI, Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni (no Au), Electrolytic Ni / Hard Au, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Resistors

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQ(VQE-11-021244), VQ(VQE-14-028500), VQ(VQE-15-028809)

Composition: H - Homogenous thermoplastic base material printed boards Rigid Base Material: Woven glass, reinforced, hydrocarbon resin, with ceramic fill

Max. Panel Size: 18" x 24" Max. Number of Layers: 9 Max. Board Thickness: .0844"

Min. Hole Size: .0135" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 7.4:1 Through-Hole Min. Conductor Width/Space: .004"/.003" Hole Preparation: Plasma Desmear

Hole Wall Conductive Coating: Electroless Copper Copper Plating: Direct Current Plate, Pulse Plate

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL

MANUFACTURER INFORMATION:

Viasystems Toronto Inc.

8150 Sheppard Avenue East, Scarborough, M1B 5K2,

Ontario Canada

PLANT LOCATION:

Same Address as Manufacturer

CAGE Code: 3AF82

Phone: 416-208-2100 Fax: 416-208-2196

EMail:

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-04-006240, VQE-08-015407, VQE-09-018857, VQE-11-022676, VQE-12-023550

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 18 Max. Board Thickness: .088"

Min. Hole Size: .0098" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 8.4:1 Through-Hole Min. Conductor Width/Space: .0037"/.0028"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper,

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, ImmAg, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-04-006240, VQE-08-015407, VQE-09-018857, VQE-11-022676, VQE-12-023550

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .093"

Min. Hole Size: .0091" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 1:1 Microvia, 9.6:1 Through-Hole Min. Conductor Width/Space: .004"/.003"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Hole Fill/Via Plug: Conductive, Non-Conductive

Solder Resist: Liquid Photoimageable

Finish System: ENIG, HASL, ImmAg, Ni/Pd/Au

Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Sequential Lamination

MANUFACTURER INFORMATION: PLANT LOCATION:

Westak of Oregon

3941 24th Avenue, Forest Grove, OR, 97116 US

Same Address as Manufacturer

CAGE Code: 65745

Phone: 503-359-3593
Fax: 503-357-5332
EMail: or-qa@westak.com

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-13-026434, VQE-14-027108

Rigid Base Material: GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .11"

Min. Hole Size: .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 9.3:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2 Qualification Letters: VQE-13-026434, VQE-14-027109

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 10
Max. Board Thickness: .11"

Min. Hole Size: .008" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10.6:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Permanganate Desmear, Plasma Etchback

Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Solder Resist: Dry Film, Liquid Photoimageable

Finish System: ENIG, HASL

SECTION II LIST OF MANUFACTURERS AND ASSOCIATED SPECIFICATION		
AC Universal Circuits LLC 8860 Zachary Lane North, Maple Grove, MN, 55369-4524 US CAGE Code: 45032	 ✓ MIL-PRF-31032/1	
Accurate Circuit Engineering 3019 S. Kilson Drive, Santa Ana, CA, 92707 US CAGE Code: 0MNN9	 ✓ MIL-PRF-31032/1	
Advanced Circuits - Tempe Division 229 S. Clark Drive, Tempe, AZ, 85281-3073 US CAGE Code: 6RJS1	 ✓ MIL-PRF-31032/1	
Airborn Flexible Circuits, Inc. 11 Dohme Avenue, Toronto, M4B 1Y7, Ontario Canada CAGE Code: 38661	MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 Custom MIL-PRF-31032/2 MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 MIL-PRF-31032/6	
American Standard Circuits 475 Industrial Drive, West Chicago, IL, 60185 US CAGE Code: 4AA34	 ✓ MIL-PRF-31032/1	
Amphenol Printed Circuits 91 Northeastern Boulevard, Nashua, NH, 03062 US CAGE Code: 57034	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ Custom ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/6 	
Calumet Electronics Corp. 25830 Depot Street, Calumet, MI, 49913-1985 US CAGE Code: 65337	 ✓ MIL-PRF-31032/1	
Cirexx International, Inc. 791 Nuttman Street, Santa Clara, CA, 95054 US CAGE Code: 4MEG7	✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ☐ Custom ✓ MIL-PRF-31032/2 ☐ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ☐ MIL-PRF-31032/6	
Colonial Circuits, Inc. 1026 Warrenton Road, Fredericksburg, VA, 22406-6200 US CAGE Code: 6T499	✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ☐ Custom ✓ MIL-PRF-31032/2 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6	
Compunetics Inc. 700 Seco Rd, Monroeville, PA, 15146 US CAGE Code: 30598	 ✓ MIL-PRF-31032/1	
Cosmotronic, Inc. 16721 Noyes Avenue, Irvine, CA, 92606-5176 US CAGE Code: 63695	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6 	
Dynamic & Proto Circuits, Inc. 869 Barton Street, Stoney Creek, L8E 5G6, Ontario Canada CAGE Code: 38898	✓ MIL-PRF-31032/1	
Electro Plate Circuitry, Inc. 1430 Century Drive, Carrollton, TX, 75006 US CAGE Code: 79616	✓ MIL-PRF-31032/1	

SECTIO LIST OF MANUFACTURERS AND A	
Electrotek Corp. 7745 S. 10th Street, Oak Creek, WI, 53154 US CAGE Code: 66030	 ✓ MIL-PRF-31032/1
Firan Technology Group 250 Finchdene Square, Scarborough, M1X 1A5, Ontario Canada CAGE Code: L2665	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6
FTG Circuits, Inc. (Chatsworth) 20750 Marilla Street, Chatsworth, CA, 91311 US CAGE Code: 30803	MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 Custom MIL-PRF-31032/2 MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 MIL-PRF-31032/6
Gorilla Circuits 1445 Old Oakland Rd, San Jose, CA, 95112 US CAGE Code: 3C7D2	 ✓ MIL-PRF-31032/1
Graphic Plc Lords Meadow Industrial Estate, Crediton, Devon, EX17 IHN UK CAGE Code: U4538	 ✓ MIL-PRF-31032/1
Hamby Corporation 27704 Avenue Scott, Valencia, CA, 91355-1218 US CAGE Code: 07284	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6
Hans Brockstedt GmbH Clara-Immerwahr-Strabe 7, 24145 Kiel Germany CAGE Code: C4831	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6
Holaday Circuits, Inc. 11126 Bren Road West, Minnetonka, MN, 55343 US CAGE Code: 59554	✓ MIL-PRF-31032/1
Hughes Circuits, Inc. 540 S. Pacific Street, San Marcos, CA, 92078-4056 US CAGE Code: 1KXU6	 ✓ MIL-PRF-31032/1
ISU Petasys 12930 Bradley St., Sylmar, CA, 91342 US CAGE Code: 1WFH9	 ✓ MIL-PRF-31032/1
KCA Electronics, Inc. 223 N. Crescent Way, Anaheim, CA, 92801 US CAGE Code: 1VUH8	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6
Lockheed Martin Mission Systems & Training 1801 State Route 17C, Owego, NY, 13827 US CAGE Code: 03640	✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ☐ Custom ✓ MIL-PRF-31032/2 ☐ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ☐ MIL-PRF-31032/6
Lone Star Circuits 901 Hensley Drive, Wylie, TX, 75098-4909 US CAGE Code: 04RV5	✓ MIL-PRF-31032/1

SECTION II LIST OF MANUFACTURERS AND ASSOCIATED SPECIFICATION		
Micom Corp. 475 Old Highway 8 NW, New Brighton, MN, 55112 US CAGE Code: 34076	✓ MIL-PRF-31032/1	
Midwest Printed Circuit Services 1741 Circuit Drive, Round Lake Beach, IL, 60073 US CAGE Code: 0YYS4	 ✓ MIL-PRF-31032/1	
Murrietta Circuits, Inc. 5000 E. Landon Drive, Anaheim, CA, 92807 US CAGE Code: 0EJD7	✓ MIL-PRF-31032/1	
Pioneer Circuits, Inc. 3000 S. Shannon Street, Santa Ana, CA, 92704-6321 US CAGE Code: 65723	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6 	
PNC, Inc. 115 East Centre Street, Nutley, NJ, 07110 US CAGE Code: 66766	✓ MIL-PRF-31032/1	
Printed Circuits, Inc. 1200 West 96th Street, Bloomington, MN, 55431-2606 US CAGE Code: 65114	✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ☐ Custom ✓ MIL-PRF-31032/2 ☐ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ☐ MIL-PRF-31032/6	
Pro-Tech Interconnect Solutions LLC 4300 Peavey Road, Chaska, MN, 55318 US CAGE Code: 3CP65	✓ MIL-PRF-31032/1	
Sanmina-SCI (Costa Mesa) 2945 Airway Avenue, Costa Mesa, CA, 92626 US CAGE Code: 3BKL5	✓ MIL-PRF-31032/1	
Sanmina-SCI (Owego) 1200 Taylor Rd., Owego, NY, 13827 US CAGE Code: 4GZ84	✓ MIL-PRF-31032/1	
Sanmina-SCI (San Jose) 2050 Bering Drive, San Jose, CA, 95131 US CAGE Code: 3DR67	✓ MIL-PRF-31032/1	
Speedy Circuits, Inc. 5331 McFadden Avenue, Huntington Beach, CA, 92649-1204 US CAGE Code: 66982	✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ☐ Custom ✓ MIL-PRF-31032/2 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6	
Teledyne Printed Circuit Technology 110 Lowell Road, Hudson, NH, 03051 US CAGE Code: 22958	MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 Custom MIL-PRF-31032/2 MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 MIL-PRF-31032/6	
Thales Nederland B.V. Haaksbergerstraat 49, 7554PA Hengelo The Netherlands CAGE Code: H0203	✓ MIL-PRF-31032/1	

SECTION II LIST OF MANUFACTURERS AND ASSOCIATED SPECIFICATION		
TTM Technologies (Santa Ana) 2630 South Harbor Boulevard, Santa Ana, CA, 92704 US CAGE Code: 1WQ42	 ✓ MIL-PRF-31032/1	
TTM Technologies (Santa Clara) 407 Mathew Street, Santa Clara, CA, 95050 US CAGE Code: 65916	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6 	
TTM Technologies (Stafford) 4 Old Monson Road, Stafford, CT, 06075 US CAGE Code: 5L706	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/2 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6 	
Unicircuit, Inc. 8192 Southpark Lane, Littleton, CO, 80120 US CAGE Code: 66311	 ✓ MIL-PRF-31032/1	
Viasystems Technologies Corp., LLC - Anaheim 3140 East Coronado Street, Anaheim, CA, 92806 US CAGE Code: 0BSG1	 ✓ MIL-PRF-31032/1	
Viasystems Technologies Corp., LLC - Cleveland 7 Ascot Parkway, Cuyahoga Falls, OH, 44223 US CAGE Code: 7Z463	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ Custom ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6 	
Viasystems Technologies Corp., LLC - Denver 10570 Bradford Road, Littleton, CO, 80127-4211 US CAGE Code: 75815	 ✓ MIL-PRF-31032/1	
Viasystems Technologies Corp., LLC - North Jackson 12080 DeBartolo Drive, North Jackson, OH, 44451 US CAGE Code: 0GN71	 ✓ MIL-PRF-31032/1 ✓ MIL-PRF-31032/4 ✓ MIL-PRF-31032/5 ✓ MIL-PRF-31032/3 ✓ MIL-PRF-31032/6 	
Viasystems Technologies Corp., LLC - San Jose 355 Turtle Creek Court, San Jose, CA, 95125-1316 US CAGE Code: 0MHG5	 ✓ MIL-PRF-31032/1	
Viasystems Technologies Corp., LLC - Sterling 1200 Severn Way, Sterling, VA, 20166-8904 US CAGE Code: 0K703	 ✓ MIL-PRF-31032/1	
Viasystems Toronto Inc. 8150 Sheppard Avenue East, Scarborough, M1B 5K2, Ontario Canada CAGE Code: 3AF82	 ✓ MIL-PRF-31032/1	
Westak of Oregon 3941 24th Avenue, Forest Grove, OR, 97116 US CAGE Code: 65745	 ✓ MIL-PRF-31032/1	